

Title (en)

Electrode forming method for surface acoustic wave device

Title (de)

Verfahren zur Herstellung einer Elektrode für akustische Oberflächenwellenanordnung

Title (fr)

Méthode de formation d'électrode pour dispositif à ondes acoustiques de surface

Publication

**EP 0657998 B1 19990929 (EN)**

Application

**EP 94119164 A 19941205**

Priority

- CA 2137307 A 19941205
- JP 33929393 A 19931202
- US 34931094 A 19941205

Abstract (en)

[origin: EP0657998A1] An electrode forming method for a surface acoustic wave device is adapted to form a film of an electrode material on a piezoelectric substrate to be crystallographically oriented in a constant direction while carrying out ion assistance at prescribed ion energy, in a film formation process employing a film forming method such as evaporation, sputtering, IBS (ion beam sputtering), CVD (chemical vapor deposition), plasma CVD, MBE (molecular beam epitaxy), ICB (ionized cluster beam) or laser ablation. <IMAGE>

IPC 1-7

**H03H 9/02**; **H03H 3/08**

IPC 8 full level

**H03H 3/08** (2006.01); **H03H 9/02** (2006.01)

CPC (source: EP US)

**H03H 3/08** (2013.01 - EP US); **H03H 9/02929** (2013.01 - EP US)

Cited by

DE10134092B4; FR2864350A1; EP1729414A3; CN117535790A; US7602099B2

Designated contracting state (EPC)

DE FR GB

DOCDB simple family (publication)

**EP 0657998 A1 19950614**; **EP 0657998 B1 19990929**; CA 2137307 A1 19960606; CA 2137307 C 19990302; JP 3208977 B2 20010917; JP H07162255 A 19950623; US 5558711 A 19960924

DOCDB simple family (application)

**EP 94119164 A 19941205**; CA 2137307 A 19941205; JP 33929393 A 19931202; US 34931094 A 19941205